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| <p align="center">NATIONAL PHASE UTILITY APPLICATION</p> <p align="center">Transmittal to the (DO/EO/US) Under 35 USC 371</p> | <p>Attorney Docket No.: SHIGA7.045APC First Named Inventor: Yasuo Masuda Int'l Application No.: PCT/JP2004/012235 Int'l Filing Date: August 19, 2004 Priority Date Claimed: September 18, 2003 (2003-325953) Title: POSITIVE PHOTORESIST COMPOSITION AND RESIST PATTERN FORMATION Express Mail Label No.: EV 465554469 US</p> |
| <p>Direct all correspondence to Customer No.: 20995 Date: February 14, 2006 Page 1 of 2</p> | |

10/568126

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The following enclosures are transmitted herewith to be filed in the patent application of:

Inventors:

1. Yasuo Masuda
2. Toshiki Okui

APPLICATION ELEMENTS:

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) A copy of the International Application as published (35 U.S.C. § 371(c)(2)) is attached hereto.
 - (X) PCT/IB/308 enclosed.
- (X) An English translation of the International Application as filed is not required.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.
- (X) International Search Report for the International Application
- (X) An Oath or Declaration signed by the inventors (35 U.S.C. § 371(c)(4)).

OTHER APPLICATION PARTS:

- (X) Preliminary Amendment in 3 pages.
- (X) Recordation form cover sheet and Assignment in 3 total pages (cover sheet & assignment).
- (X) Power of Attorney form and copy of assignment in 4 pages.
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
 - (X) Listing 10 references.
 - (X) Enclosing 7 references.
- (X) Return prepaid postcard.

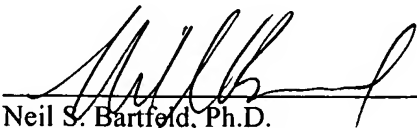
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|--|---|
| NATIONAL PHASE UTILITY APPLICATION Transmittal to the (DO/EO/US) Under 35 USC 371 | Attorney Docket No.: SHIGA7.045APC First Named Inventor: Yasuo Masuda Int'l Application No.: PCT/JP2004/012235 Int'l Filing Date: August 19, 2004 Priority Date Claimed: September 18, 2003 (2003-325953) Title: POSITIVE PHOTORESIST COMPOSITION AND RESIST PATTERN FORMATION Express Mail Label No.: EV 465554469 US |
| Direct all correspondence to Customer No.: 20995 | |
| Date: February 14, 2006 Page 2 of 2 | |

FILING FEES:

| FEE CALCULATION | | | | |
|--|---|--------------|----------------------|----------------|
| FEE TYPE & DETERMINATION | | LARGE FEE | CALCULATION | TOTAL |
| Basic Filing Fee under 1.492(a) | | 1631 (\$300) | | \$300 |
| Search Fee under 1.492(b) (enter one in TOTAL column) | | | | |
| (1) | USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4) | 1640 (\$0) | | \$400 |
| (2) | USPTO was the ISA (noncompliant claims) | 1641 (\$100) | | |
| (3) | Foreign Search Report Enclosed | 1642 (\$400) | | |
| (4) | No Search Report Enclosed | 1632 (\$500) | | |
| Examination Fee under 1.492(c) (enter one in TOTAL column) | | | | |
| (1) | USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4) | 1643 (\$0) | | \$200 |
| (2) | Non US IPEA or Noncompliant Claims | 1633 (\$200) | | |
| Excess Claims | 12 - 20 = 0 | 1615 (\$50) | 0 x 50 = | \$0 |
| Excess Ind. Claims | 1 - 3 = 0 | 1614 (\$200) | 0 x 200 = | \$0 |
| Multiple Dep. Claim | | 1616 (\$360) | | \$360 |
| Assignment | | 8021 (\$40) | 1 x 40 = | \$40 |
| | | | TOTAL FEE DUE | \$1,300 |
| TOTAL FEE PAID (If Different Than Fee Due) | | | | N/A |

(X) A check in the amount of \$1,300 to cover the Total Fee Due is enclosed.

The Commissioner is hereby authorized to charge any additional fees which may be required, now or in the future, or credit any overpayment to Account No. 11-1410.


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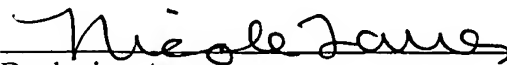
Attorney Docket No. : SHIGA7.045APC
Applicant(s) : Masuda et al.
For : POSITIVE PHOTORESIST COMPOSITION
AND RESIST PATTERN FORMATION
Agent : Neil S. Bartfeld, Ph.D.
"Express Mail" Label No. : EV 465554469 US
Date of Deposit : February 14, 2006

I hereby certify that the accompanying

EV465554469US

Transmittal letter; a copy of PCT/JP2004/012235; a copy of form PCT/IB/308 for PCT/JP2004/012235; a copy of the International Search Report for PCT/JP2004/012235; Preliminary Amendment in 3 pages; SIGNED Declaration in 2 pages; Power of Attorney and copy of assignment in 4 pages; Recordation Form Cover Sheet and Assignment in 3 pages; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 10 references listed (7 enclosed); Check for Filing Fee; Return Prepaid Postcard

are being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 on the date indicated above and are addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.


Docketing Agent

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